RIFT WG

IETF110
Virtual

Chairs:
Jeff Tantsura - jefftant.ietf@gmail.com
Jeffrey Zhang - zzhang@juniper.net
Agenda

• WG Status, chairs – 05 minutes
• RIFT base spec update:
  Tony Przygienda https://tools.ietf.org/html/draft-ietf-rift-rift-12 - 10 minutes
• RIFT YANG update:
  Sandy Zhang https://tools.ietf.org/html/draft-ietf-rift-yang-02 - 05 minutes
• RIFT Applicability draft update:
• RIFT K-V Registry:
  Jordan Head https://tools.ietf.org/html/draft-head-rift-kv-registry-00 - 10 minutes
• Segment Routing in RIFT:
  Jeffrey Zhang https://tools.ietf.org/html/draft-zzhang-rift-sr-03 - 10 minutes
• Auto-EVPN with RIFT, Tony Przygienda:
  https://www.ietf.org/id/draft-head-rift-auto-evpn-00.html - 15 minutes,
• Wrap-up, chairs
WG Status

• Base spec
  • -12 revision sent to IESG for publication on 06/02/2020
  • Working on addressing Alvaro’ comments

• Applicability Statement draft
  • In WGLC, addressing comments

• YANG
  • Ongoing work

• SR work is progressing
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